	Туре	Hi	Search Text	DBs	Time Stamp	Er ro r De fi ni ti	Er ro	Ref #
1	IS&R	2	("6383905").PN.	IH. D() • . / D() •	2005/03/30 09:45			S1
2	IS&R	2		US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/03/30 09:46			S2
3	IS&R	2	("5893751").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/03/30 09:47			S3
4	IS&R	2	("5654589").PN.	IH: P() • . I P() •	2005/03/30 09:48			S4
5	BRS	3	(cmp or polish\$4) with slurry with (polysilicon or polycrystsl\$5) with line and (micro adj rough\$5 or rough\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/03/30 09:57			S9
6	BRS	9		EPO; JPO;	2005/03/30 10:07			S8

	Туре	Hi ts	Search Text	DBs	Time Stamp	Co mm en ts	De fi	Errors	Ref #
7	BRS	18	(cmp or polish\$4) with slurry with (polysilicon or polycrystsl\$5) and silicide and (micro adj rough\$5 or rough\$5)	EPO; JPO;	2005/03/30 13:09				S7
8	BRS		(cmp or polish\$4) with slurry with (polysilicon or polycrystsl\$5) and (micro adj rough\$5 or rough\$5) and slurry with size	EPO; JPO;	2005/03/30 10:19				S10
9	BRS	1	(cmp or polish\$4) with slurry with (polysilicon or polycrystsl\$5) with (micro adj rough\$5 or rough\$5) with size	EPO; JPO;	2005/03/30 10:20				S11
10	BRS	1	(cmp or polish\$4) with slurry with (polysilicon or polycrystsl\$5) with (micro adj rough\$5 or rough\$5) same size	EPO; JPO;	2005/03/30 10:20				S12

	Туре	Hi ts	Search Text	DBs	Time Stamp	Er ro r De fi ni ti	Er ro rs	Ref #
11	BRS	3	(cmp or polish\$4) with slurry with (polysilicon or polycrystsl\$5) same (micro adj rough\$5 or rough\$5) same	EPO; JPO;	2005/03/30 10:21			S13
12	BRS	3	(cmp or polish\$4) same slurry same (polysilicon or polycrystsl\$5) same (micro adj rough\$5 or rough\$5) same size	EPO; JPO;	2005/03/30 10:21			S14

	Туре	Hi ts	Search Text	DBs	Time Stamp	Co mm en ts	De fi	Er ro rs	Ref #
13	BRS	25	i i		2005/03/30 11:31				S15
14	BRS	1	(cmp or polish\$4) with slurry with (polysilicon or polycrystsl\$5) with (linewidth or line	FDO. TDO.	2005/03/30 12:22				S16

	Type	Hits	Search Text	DBs	Time	Stamp	en	Er ro r De fi ni ti on	Er ro	Ref #
15	BRS	2	illinewiarn or line	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/0 12:23	03/30				S17
16	BRS	6	<pre>(cmp or polish\$4) with slurry with (polysilicon or polycrystsl\$5) with (line adj width or line or width) and slurry with (particle or abras\$4 or size)</pre>	EPO; JPO;	2005/(12:24	03/30				S18
17	BRS	35	(cmp or polish\$4) with slurry with (polysilicon or polycrystal\$5) and (polysilicon or polycrystal\$5) with (line adj width or line or width) and slurry with (particle or abras\$4 or size)	EPO; JPO;	2005/0 12:26)3/30				S19

	Туре	Hi ts	Search Text	DBs	Time Stamp	Co mm en ts	De fi	Errors	Ref #
18	BRS	0	HINGIVELLISCON OF	EPO: JPO:	2005/03/30 12:45				S20
19	BRS	3		EPO; JPO; DERWENT; IBM_TDB	2005/03/30 12:46				S21
20	BRS		(polysilicon or polycrystsl\$5) with silicide near phase	EPO; JPO;	2005/03/30 13:00				S22
21	BRS	3	(polysilicon or polycrystal\$5) with silicide with phase and (polysilicon or polycrystal\$4) with (cmp or polish\$4) with slurry	US-PGPUB; USPAT; EPO; JPO;	2005/03/30 13:01				S24

	Туре	Hi ts	Search Text	DBs	Time Stamp	en	Er ro r De fi ni ti on	Errors	Ref #
22	BRS	24	(polysilicon or polycrystal\$5) with silicide with phase and (polysilicon or polycrystal\$4) with (cmp or polish\$4)	EDO. IDO.	2005/03/30 13:02				S23
23	BRS	84	(nolysilicon or	US-PGPUB; USPAT;	2005/03/30 13:10				S25
24	BRS	0 /	(nolysilicon or	US-PGPUB; USPAT;	2005/03/30 13:11				S26
25	BRS	3	(polysilicon or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/03/30 13:11				S28

	Type	Hi	Search Text	DBs	Time Stamp	Co mm en ts	fi	Er ro rs	Ref #
26	BRS	17	_	US-PGPUB; USPAT; EPO; JPO;	2005/04/02 14:28				S27
27	BRS	19	and (drain or	IH: P() • P() •	2005/04/02 14:52				S29
28	IS&R	2	("5946566").PN.	IH: P() • . P() •	2005/04/02 14:40				S30
29	BRS		(hsg or polysilicon with polish\$4) with rough\$5 with silicide and gate	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/04/02 15:03				S31
30	BRS	2	(hsg or polysilicon with polish\$4 with rough\$5) same silicide and gate and ldd	US-PGPUB; USPAT; EPO; JPO;	2005/04/02 15:04				S32
31	BRS	15	Ngilicide or	US-PGPUB; USPAT;	2005/04/02 15:19				S33

	Туре	Hi	Search Text	DBs	Time Stamp	en	Er ro r De fi ni ti	Er ro rs	Ref #
32	BRS	18	(hsg or polysilicon) with rough\$5 same (silicide or polycide) same adhes\$5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/04/02 15:30				S34
33	BRS	4		US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB	2005/04/02 15:32				S35
34	BRS	14	polysilicon with rough\$6 with adhes\$5 with (silicide or polycide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/04/02 15:37				S36
35	BRS	2	polish\$5 with	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/04/02 15:38				S37
36	BRS	6	polish\$5 same	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/04/02 15:39				S38
37	BRS	25	abras\$5 and	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/04/02 16:05				S39

	Туре	Hi	Search Text	DBs	Time Stamp	en	 Er ro rs	Ref #
38	BRS	21	(nolveilicon with	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/04/02 16:09			S40
39	BRS	21	(polysilicon with		2005/04/02 17:46			S41